L Number	Hits	Search Text	DB	Time stamp
1 Number	2	("5415704").PN.	USPAT;	2003/04/16 14:20
'	-		EPO; JPO;	
			DERWENT;	
			IBM_TDB	
	114	ion adj bombardment and chromium adj (layer or coating or substrate)	USPAT;	2003/04/09 08:54
-		Total day bonnour direction and the bonnour day (any transfer or bonnour direction)	EPO; JPO;	
			DERWENT;	
			IBM_TDB	
_	152	ion adj plating and chromium adj (layer or coating or substrate)	USPAT;	2003/04/09 10:56
-	132	lon adj plating and emonitum adj (layer or coaring or caccinate)	EPO; JPO;	
			DERWENT;	
			IBM TDB	
	7260	(148/240-287).CCLS.	USPAT;	2003/04/09 08:56
_	7200	(140/240-207).0005.	EPO; JPO;	2005/01/07 00/00
			DERWENT;	
			IBM_TDB	1
	176	(148/246) CCLS	USPAT;	2003/04/16 09:41
-	176	(148/246).CCLS.	EPO; JPO;	2003/04/10 07.41
			DERWENT;	
		(149/076) CCLS	IBM_TDB	2002/04/00 00:57
-	232	(148/276).CCLS.	USPAT;	2003/04/09 09:57
			EPO; JPO;	
			DERWENT;	
			IBM_TDB	
-	262	(148/277).CCLS.	USPAT;	2003/04/09 09:57
			EPO; JPO;	
			DERWENT;	
			IBM_TDB	
-	87	(148/280).CCLS.	USPAT;	2003/04/09 09:57
			EPO; JPO;	
			DERWENT;	
			IBM_TDB	
-	187	(148/286).CCLS.	USPAT;	2003/04/09 09:58
			EPO; JPO;	
			DERWENT;	
			IBM TDB	
-	454	(427/419.1).CCLS.	USPAT;	2003/04/09 09:58
			EPO; JPO;	
1			DERWENT;	
1			IBM TDB	
-	898	(427/419.2).CCLS.	USPAT;	2003/04/09 09:59
]			EPO; JPO;	
			DERWENT;	
			IBM_TDB	
_	8417	((148/240-287).CCLS.) ((148/246).CCLS.) ((148/276).CCLS.)	USPAT;	2003/04/16 09:24
	5117	((148/277).CCLS.) ((148/280).CCLS.) ((148/286).CCLS.)	EPO; JPO;	
[((427/419.1).CCLS.) ((427/419.2).CCLS.)	DERWENT;	
		((12.1.17.17.10000.)) ((12.1.117.12).0000.)	IBM_TDB	
_	23	conversion adj coating and chromium adj (substrate or layer)	USPAT;	2003/04/16 09:25
	2.5	conversion and coating and enrollment and (substrate of layer)	EPO; JPO;	2003/07/10 07.23
	ĺ		DERWENT;	
			IBM TDB	
_	17	carbonyl same (tungsten molybdenum chomium iron nickel) and	USPAT;	2003/04/09 10:42
-	17	carbonyl same (tungsten molyodenum chomium from nickel) and chromium adj (layer or coating or substrate)		2003/04/09 10:42
	ļ	Chromium auj (layer of coating of substrate)	EPO; JPO;	
	ļ		DERWENT;	
	3.4	the modern testing and plane and the conditions and the conditions to the conditions	IBM_TDB	2002/04/00 10 50
-	34	ion adj plating and chromium and wear adj resistant adj coating	USPAT;	2003/04/09 10:56
	ł		EPO; JPO;	
			DERWENT;	
			IBM_TDB	
-	1	conversion adj coating and chromium adj (substrate or layer)	USOCR	2003/04/09 10:43
-	26	carbonyl same (tungsten molybdenum chomium iron nickel) and	USOCR	2003/04/09 10:43
	į	chromium adj (layer or coating or substrate)		
-	1	ion adj plating and chromium and wear adj resistant adj coating	USOCR	2003/04/09 10:43
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Search History 4/16/03 3:32:51 PM Page 1

-	20	ion adj implantation and chromium and wear adj resistant adj coating	USPAT; EPO; JPO;	2003/04/09 10:56
-	205	ion adj implantation and chromium adj (layer or coating or substrate)	DERWENT; IBM_TDB USPAT; EPO; JPO; DERWENT;	2003/04/09 10:57
	8421	((148/240-287).CCLS.) ((148/246).CCLS.) ((148/276).CCLS.) ((148/277).CCLS.) ((148/280).CCLS.) ((148/286).CCLS.) ((427/419.1).CCLS.) ((427/419.2).CCLS.)	IBM_TDB USPAT; EPO; JPO; DERWENT;	2003/04/16 09:25
-	1923	chromium adj (substrate or layer) and (CF or CO or CO?sub?? or CF?sub?? or CS or CS?sub??)	IBM_TDB USPAT; EPO; JPO; DERWENT;	2003/04/16 09:27
-	331	chromium adj (substrate or layer) and (formic adj acid or methyl adj alcohol or ethyl adj alcohol or acetone)	IBM_TDB USPAT; EPO; JPO; DERWENT;	2003/04/16 09:40
-	31	chromium adj (substrate or layer) and (CF or CO or CO?sub?? or CF?sub?? or CS or CS?sub??) and (((148/240-287).CCLS.) ((148/246).CCLS.) ((148/276).CCLS.) ((148/280).CCLS.) ((148/286).CCLS.) ((427/419.1).CCLS.) ((427/419.2).CCLS.)	IBM_TDB USPAT; EPO; JPO; DERWENT; IBM_TDB	2003/04/16 09:40
-	2	((427/413.2).CCL3.)) ("5873951").PN.	USPAT; EPO; JPO; DERWENT; IBM TDB	2003/04/16 09:31
-	7	chromium adj (substrate or layer) and (formic adj acid or methyl adj alcohol or ethyl adj alcohol or acetone) and (((148/240-287).CCLS.) ((148/246).CCLS.) ((148/277).CCLS.) ((148/280).CCLS.) ((148/286).CCLS.) ((427/419.1).CCLS.)	USPAT; EPO; JPO; DERWENT; IBM_TDB	2003/04/16 09:42
-	177	((427/419.2).CCLS.)) (148/246).CCLS.	USPAT; EPO; JPO; DERWENT; IBM TDB	2003/04/16 09:42
-	463	(148/264).CCLS.	USPAT; EPO; JPO; DERWENT; IBM_TDB	2003/04/16 09:42
-	355	chromium adj (substrate or layer) and (CF or CO or CO?sub?? or CF?sub?? or CS or CS?sub??) and (hardness or friction or lubricious or lubric\$5)	USPAT; EPO; JPO; DERWENT; IBM_TDB	2003/04/16 09:49
-	519	chromium adj (coat\$4 or substrate or layer) and (CF or CO or CO?sub?? or CF?sub?? or CS or CS?sub??) and (hardness or friction or lubricious or lubric\$5)	USPAT; EPO; JPO; DERWENT; IBM TDB	2003/04/16 09:55
-	7	chromium adj (substrate or layer) and (CF or CO or CO?sub?? or CF?sub?? or CS or CS?sub??) and (hardness or friction or lubricious or lubric\$5) and 148/240-287.ccls.	USPAT; EPO; JPO; DERWENT; IBM_TDB	2003/04/16 09:55
-	145	chromium adj (coat\$4 or substrate or layer) and (CF or CO or CO?sub?? or CF?sub?? or CS or CS?sub??) and (hardness or friction or lubricious or lubric\$5)	USOCR	2003/04/16 10:00
-	16	(chromium adj (coat\$4 or substrate or layer) and (CF or CO or CO?sub?? or CF?sub?? or CS or CS?sub??) and (hardness or friction or lubricious or lubric\$5)) and 148/240-287.ccls.	USPAT; EPO; JPO; DERWENT; IBM_TDB	2003/04/16 10:00
-	3	chromium adj (substrate or layer) and (CF or CO or CO?sub?? or CF?sub?? or CS or CS?sub??) and (hardness or friction or lubricious or lubric\$5) and 148/240-287.ccls.	USOCR	2003/04/16 10:20

	145	chromium adj (coat\$4 or substrate or layer) and (CF or CO or CO?sub??	USOCR	2003/04/16 10:00
-	143	or CF?sub?? or CS or CS?sub??) and (hardness or friction or lubricious		
	4	or lubric\$5) chromatizing and (hardness or friction or lubricious or lubric\$5) and	USPAT;	2003/04/16 10:03
-	4	148/240-287.ccls.	EPO; JPO;	2000/0 1110 10100
		140/240 207.0013.	DERWENT;	
			IBM_TDB	
-	4	chromatiz\$4 and (hardness or friction or lubricious or lubric\$5) and	USPAT;	2003/04/16 10:20
		148/240-287.ccls.	EPO; JPO;	
	1		DERWENT;	
	1		IBM_TDB	2002/04/16 10 20
-	0	chromatiz\$4 and medical adj implant	USPAT;	2003/04/16 10:20
			EPO; JPO;	
			DERWENT; IBM_TDB	
		chromium adj (substrate or layer) and medical adj implant	USOCR	2003/04/16 10:21
•	0 2	chromium adj (substrate of layer) and medical adj implant	USPAT;	2003/04/16 10:21
•	2	conformation and (substrate of layer) and inedical and implant	US-PGPUB:	2003/04/10 10:21
			EPO; JPO;	
			DERWENT:	
			IBM TDB	
-	2	chromium adj (substrate or layer) and medical adj implant	USPĀT;	2003/04/16 10:21
			US-PGPUB;	
			EPO; JPO;	
			DERWENT;	
			IBM_TDB	
_	26	chromium and (hardness or friction or lubricious or lubric\$5) and medical	USPAT;	2003/04/16 12:33
		adj implant	EPO; JPO;	
			DERWENT;	
			IBM TDB	